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Optics and photonics - Microlens arrays - Part 1: Vocabulary (ISO/DIS 14880-1:2017)

Optik und Photonik - Mikrolinsenarrays - Teil 1: Begriffe (ISO/DIS 14880-1:2017)

Optique et photonique - Réseaux de microlentilles - Partie 1: Vocabulaire (ISO/DIS 14880-1:2017)

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Part 1: **Vocabulary**

Optique et photonique — Réseaux de microlentilles — Partie 1: Vocabulaire

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Foreword

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The procedures used to develop this document and those intended for its further maintenance are described in the ISO/IEC Directives, Part 1. In particular the different approval criteria needed for the different types of ISO documents should be noted. This document was drafted in accordance with the editorial rules of the ISO/IEC Directives, Part 2 (see www.iso.org/directives).

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For an explanation on the meaning of ISO specific terms and expressions related to conformity assessment, as well as information about ISO's adherence to the World Trade Organization (WTO) principles in the Technical Barriers to Trade (TBT) see the following URL: www.iso.org/iso/foreword.html.

The committee responsible for this document is ISO/172 Optics and Photonics, Subcomittee SC 9 Electro-optical systems.

SIST EN ISO 14880-1:2019

This second edition cancels and replaces the first edition (ISO 14880-1:2001), which has been technically revised. It also incorporates the Technical Corrigenda ISO 14880-1:2001/Cor 1:2003 and ISO 14880-1:2001/Cor 2:2005.

ISO 14880 consists of the following parts, under the general title *Optics and photonics — Microlens arrays*:

- Part 1: *Vocabulary*
- Part 2: *Test methods for wavefront aberrations*
- Part 3: *Test methods for optical properties other than wavefront aberrations*
- Part 4: Test methods for geometrical properties
- Part 5: (Technical Report) Guidance on testing

Introduction

The aim of this part of ISO 14880 is to clarify the terms used in the field of microlens arrays.

Microoptics and microlens arrays are found in many modern optical devices.[1] They are used as coupling optics for detector arrays, the digital camera being an example of a mass market application. They are used to enhance the optical performance of liquid crystal displays to couple arrays of light sources and to direct illumination for example in 2D and 3D television, mobile phone and portable computer displays. Microlens arrays are used in wavefront sensors for optical metrology and astronomy, lightfield sensors for three–dimensional photography and microscopy and in optical parallel processor elements.

Multiple arrays of microlenses can be assembled to form optical systems such as optical condensers, controlled diffusers and superlenses.[2][3] Furthermore, arrays of microoptical elements such as micro-prisms and micro-mirrors are used.[4][5]

The expanded market in microlens arrays has generated a need to agree on basic terms and definitions for microlens arrays and systems and this part of ISO 14880 aims to satisfy that need.

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Optics and photonics — Microlens arrays — Part 1: Vocabulary

1 Scope

This part of ISO 14880 defines terms for microlens arrays. It applies to microlens arrays which consist of arrays of very small lenses formed inside or on one or more surfaces of a common substrate and systems. The aim of this part of ISO 14880 is to improve the compatibility and interchangeability of lens arrays from different suppliers and to enhance the development of technology using microlens arrays.

2 Normative references

There are no normative references in this document.

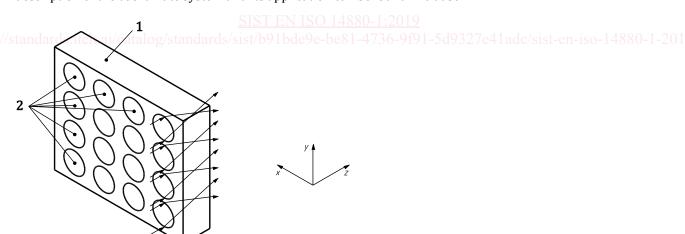
3 Terms and definitions

For the purposes of this document, the following terms and definitions apply.

ISO and IEC maintain terminological databases for use in standardization at the following addresses:

- IEC Electropedia: available at http://www.electropedia.org/
- ISO Online browsing platform: available at http://www.iso.org/obp

NOTE 1 The coordinate system used for the description of the microlenses can be found in figure 1. The description of the coordinate system and its application can be found in clause 4.



Key

- 1 Substrate
- 2 Microlenses

Figure 1 — Microlens array with Cartesian coordinate system

NOTE 2 Five common types of microlenses are illustrated in figure 5 and described in clause 5.

3.1 Symbols and units of measure

Table 1 lists symbols and units which are used in this part of ISO 14880.

Table 1 — Symbols and units of measure

Table 1 Symbols and units of measure			
Symbol	Unit	Term	
$A_{\rm d}$	mm ²	diffraction-limited optical aperture	
$A_{ m g}$	mm ²	geometric aperture	
a_{1}, a_{2}	mm	lens radius	
2 <i>a</i> ₁ , 2 <i>a</i> ₂	mm	lens width	
$D_{\rm n}$	mm ⁻²	lens density	
h	mm	surface modulation depth	
L_1, L_2	mm	edge lengths of substrate	
NA	none	numerical aperture	
<i>NA</i> _d	none	diffraction-limited numerical aperture	
$NA_{\rm g}$	none	geometric numerical aperture	
n (x, y, z)	none	refractive index 2 60 S	
n_0	tone //	refractive index at the centre of the lens	
$P_{x'}$, P_{y}	mm	pitch and Proview	
$f_{\mathrm{E,b}}$	mm	effective back focal length	
$f_{\mathrm{E,f}}$	mm SIS	effective front focal length 9	
ital Rg/sta	indards/sist/b	radius of curvature	
S_{x}, S_{y}, S_{z}	mm	coordinates of focal spot position	
ΔS_{x} , ΔS_{y} , ΔS_{z}	mm	focal spot position shift	
T	mm	thickness of substrate	
$T_{\rm c}$	mm	physical thickness	
w_{x}, w_{y}	mm	focal spot size	
X, Y, Z	mm	coordinates of lens aperture centre position	
0	degree	acceptance angle	
$\Phi_{ m rms}$	parts of wavelength	wavefront aberration	
λ	nm	wavelength	
$v_{ m eff}$	none	effective Abbe-number	

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